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C. Moore
Patent
P56240A

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re Application of:

SOON-CHEOL SHIN et al.

Serial No.: 09/837,549

Examiner: to be assigned

Filed: 19 April 2001

Art Unit: 2879

For: TENSION MASK FRAME ASSEMBLY FOR COLOR CATHODE RAY TUBE

INFORMATION DISCLOSURE STATEMENT

Assistant Commissioner
for Patents
Washington, D.C. 20231

Sir:

Pursuant to 37 C.F.R. §1.56, and §§1.97 and 1.98, applicant cites, provides copies, lists and briefly discusses the following art references cited by the Patent Examiner in the Korean industrial property office in an Office action issued on either the 26th or the 27th of September 2002 in the parent, co-pending Korean Priority Application No. 10-1999-0050943. All of the following documents are related and should be considered together, although the documents are listed separately in the 1449, for the convenience of the Examiner.

FOREIGN PATENT REFERENCES:

1. Korean Industrial Property Office Action, Serial No. 10-1999-0050943 issued 27 September 2002 entitled Notice to Submit Response;

2. English language translation of Notice to Submit Response issued on 27 September 2002 in Korean Priority Application No. 10-1999-0050943;
3. Korean Patent Publication No. P1999-073660 published on 5 November 1998 from Korean Patent Application No. P1997-009081 filed on the 18th of March 1997 by Tae-Hoon Lee for *A Shadow Mask for Cathode Ray Tube*; and
4. English language translation of the abstract of Korean Patent Publication No. P1999-073660 published on 5 November 1998 from Korean Patent Application No. P1997-009081 filed on the 18th of March 1997 by Tae-Hoon Lee for *A Shadow Mask for Cathode Ray Tube*).

DISCUSSION

The Korean Industrial Property Office cited the Lee '660 Korean Patent Publication to support a rejection of claims 1-5 in the Korean Priority Application No. 10-1999-0050943, with a Korean Examiner suggesting that the Lee '660 reference could be changed in design to provide "the vertical Pitch γ at the peripheral portion of an effective surface [being] an integral multiple larger than the vertical Pitch γ at the center portion thereof."

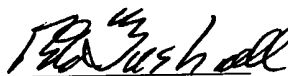
Pursuant to 37 CFR §1.97(e)(1), each item of information contained in the Information Disclosure Statement was first cited in any communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of the Information Disclosure Statement.

No fee is incurred by the filing of this Information Disclosure Statement.

This citation of foregoing references is not intended to constitute an assertion that Application has undertaken the search of the prior art. Accordingly, the Examiner is requested to take

a wide-ranging and thorough search of the relevant of art.

Respectfully submitted,



Robert E. Bushnell

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